

IN THE SPECIFICATION:

On page 1, please amend the following paragraph:

This application is a continuation of U.S. Application No. 10/141,216, filed May 7, 2002

~~The present invention is a continuation in part of Serial No. 10/036,676, filed December 21, 2001, Serial No. 10/036,727 filed December 21, 2001, Serial No. 10/006,913 filed November 29, 2001, Serial No. 10/000,991 filed November 14, 2001, Serial No. 09/943,343, filed August 29, 2001, Serial No. 09/854,097, filed May 11, 2001, Serial No. 09/848,043, filed May 3, 2001, Serial No. 09/837,150 filed April 18, 2001 and 09/829,475 filed April 9, 2001 and Serial No. 09/771,789 filed January 29, 2001, all of which are~~ is incorporated herein by reference. This invention relates to lithography light sources for integrate circuit manufacture and especially to gas discharge laser lithography light sources for integrated circuit manufacture.